

F44DPF003PCT

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PCT REQUESTOriginal (for **SUBMISSION**)

VIII-2-1	<p>Declaration: Entitlement to apply for and be granted a patent</p> <p>Declaration as to the applicant's entitlement, as at the international filing date, to apply for and be granted a patent (Rules 4.17(ii) and 51bis.1(a)(ii)), in a case where the declaration under Rule 4.17(iv) is not appropriate:</p> <p>Name (LAST, First)</p>	<p>in relation to this international application</p> <p>DU PONT-MITSUI POLYCHEMICALS CO., LTD. is entitled to apply for and be granted a patent by virtue of the following:</p>
VIII-2-1(ii)		DU PONT-MITSUI POLYCHEMICALS CO., LTD. is entitled as employer of the inventor, DEWA Yasuyuki
VIII-2-1(ii)		DU PONT-MITSUI POLYCHEMICALS CO., LTD. is entitled as employer of the inventor, HIRONAKA Yoshitaka
VIII-2-1(ix)	This declaration is made for the purposes of:	all designations except the designation of the United States of America